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Docket No.: K-281

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Tae Hoon LEE

Serial No.:

09/848,283

Group Art Unit: 2879

Confirm. No.:

7689

Examiner: Holly R. Harper

Filed:

May 4, 2001

Customer No.: 34610

For:

TENSION MASK ASSEMBLY

COMMENTS IN REPLY TO EXAMINER'S STATEMENT OF REASONS FOR ALLOWANCE

U.S. Patent and Trademark Office 2011 South Clark Place Customer Window, Mail Stop Issue Fee Crystal Plaza Two, Lobby, Room 1B03 Arlington, VA 22202

Sir:

In response to the Notice of Allowability dated April 28, 2004, Applicant respectfully submits the following Comments on Statement of Reasons for Allowance.

Applicant wishes to thank Examiner Harper for allowing claims 1-23 in the above-identified patent application. However, Applicant cannot acknowledge these statements as they do not correspond to the recitations of the claims word-for-word. Further, Applicant respectfully submits that each dependent claim is allowable for at least the additionally recited features therein and the combination thereof.

Accordingly, Applicant respectfully submits that the scope of the allowed claims should not be limited by the Examiner's statements.

Serial No. 09/726,572

Applicant respectfully requests that this paper be included in the record for purposes of satisfying the requirements under MPEP §1013.04.

> Respectfully submitted, XXIM, LLP

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Date: May 21, 2004

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